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(19) **United States**(12) **Patent Application Publication**
LEE et al.(10) **Pub. No.: US 2011/0221989 A1**(43) **Pub. Date: Sep. 15, 2011**(54) **LIQUID CRYSTAL DISPLAY DEVICE AND
METHOD OF MANUFACTURING THE SAME**(52) **U.S. Cl. 349/41; 445/24**(75) Inventors: **Dae-Won LEE**, Yongin City (KR);
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Ltd.**, Yongin-City (KR)(21) Appl. No.: **13/004,561**(22) Filed: **Jan. 11, 2011**(30) **Foreign Application Priority Data**

Mar. 9, 2010 (KR) 10-2010-0021019

Publication Classification(51) **Int. Cl.**
G02F 1/136 (2006.01)
H01J 9/00 (2006.01)(57) **ABSTRACT**

A Liquid Crystal Display (LCD) device and a method of manufacturing the same are provided. The liquid crystal molecules are inclined and rearranged in a radial shape by patterning upper and lower electrodes across and apart from each other on dummy pixels disposed on a black matrix formed in a non-display area of an LCD device and applying an electric field to a liquid crystal layer via the upper and lower electrodes. Thus, ion impurities in the non-display area can be prevented from dispersing to a display area, thereby improving edge part stains of the LCD device. The LCD device includes a first substrate including first pixel electrodes of the dummy pixels; a second substrate facing the first substrate and including first common electrodes formed across and apart from the first pixel electrodes; and a liquid crystal layer disposed between the first substrate and the second substrate, and having liquid crystal molecules rearranged by an electric field applied via the first pixel electrodes and the first common electrodes.

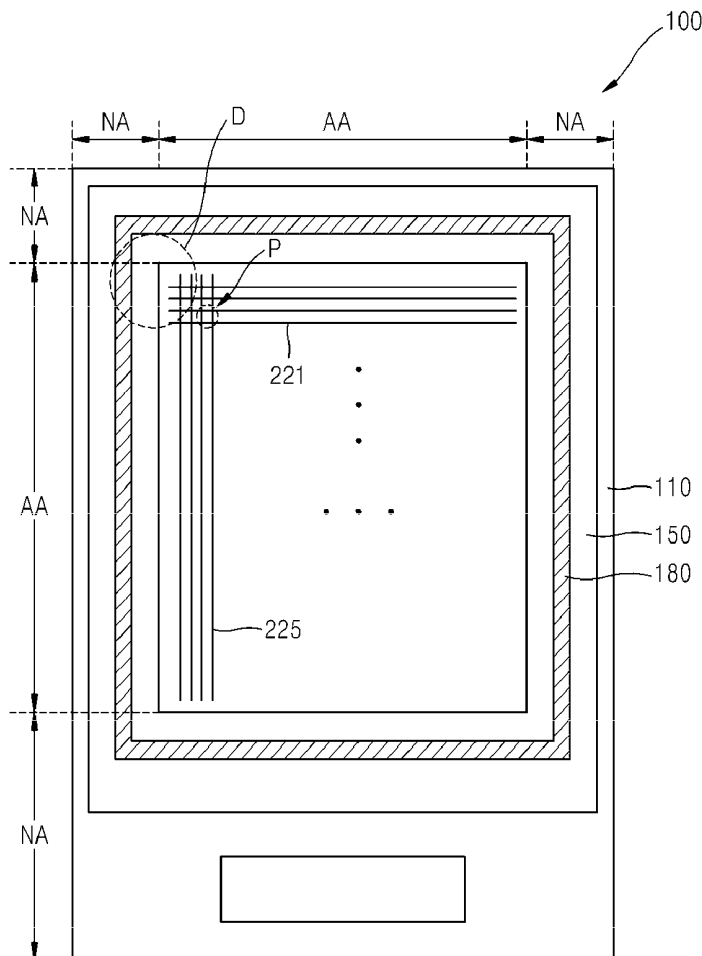


FIG. 1

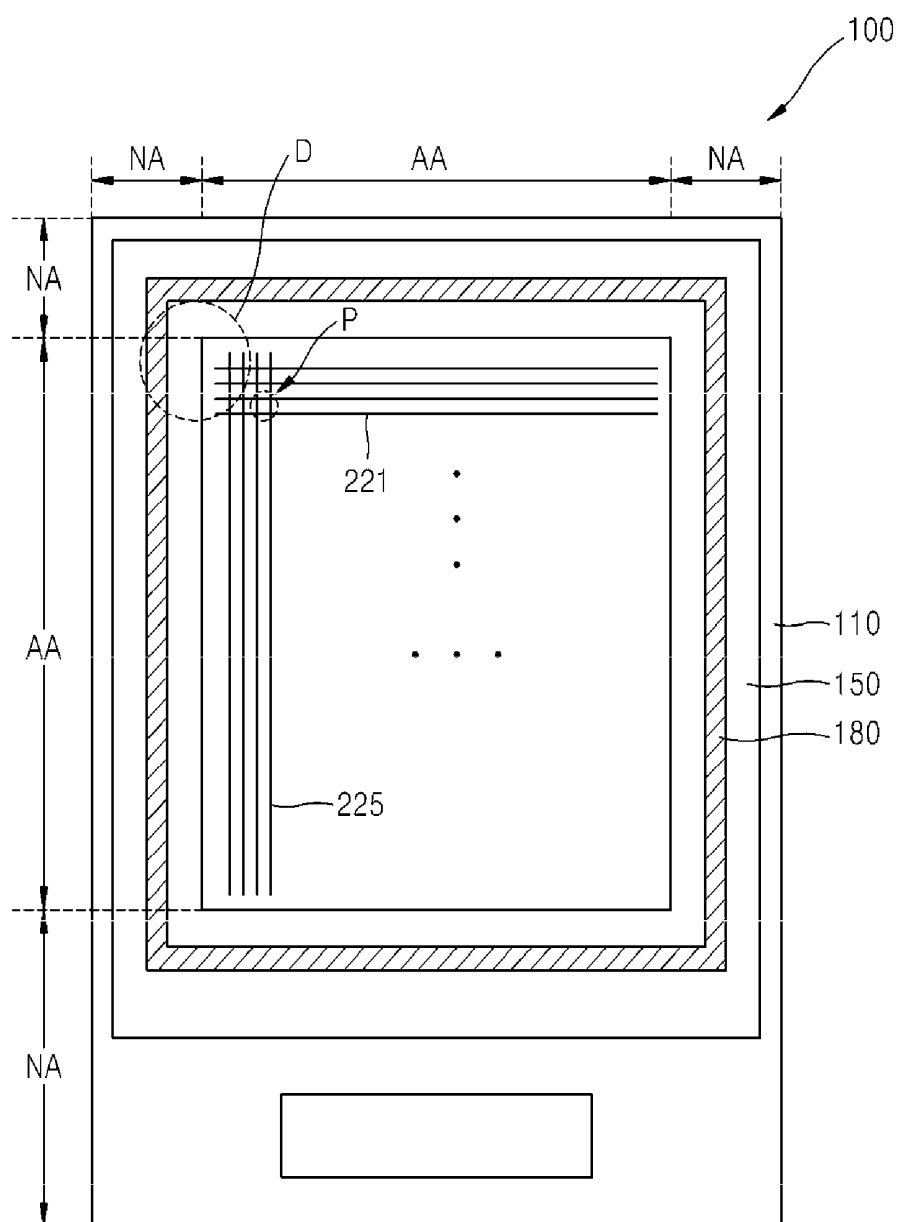


FIG. 2A

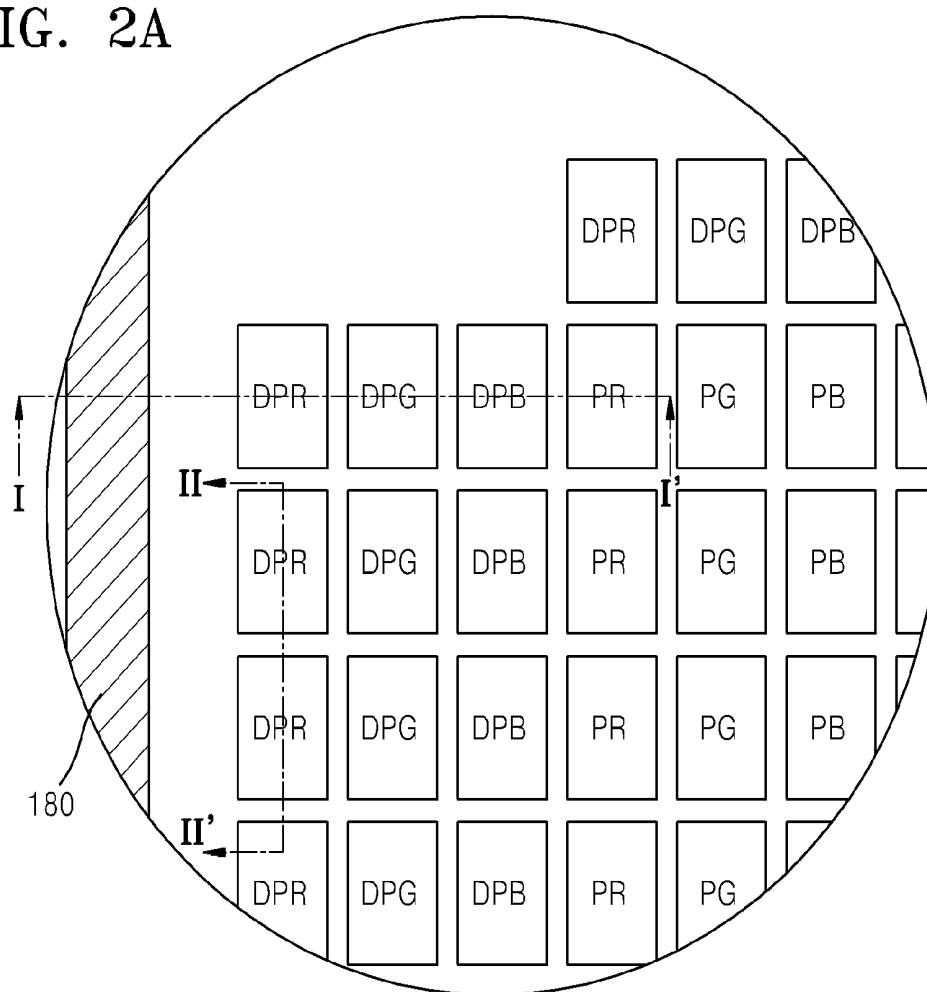


FIG. 2B

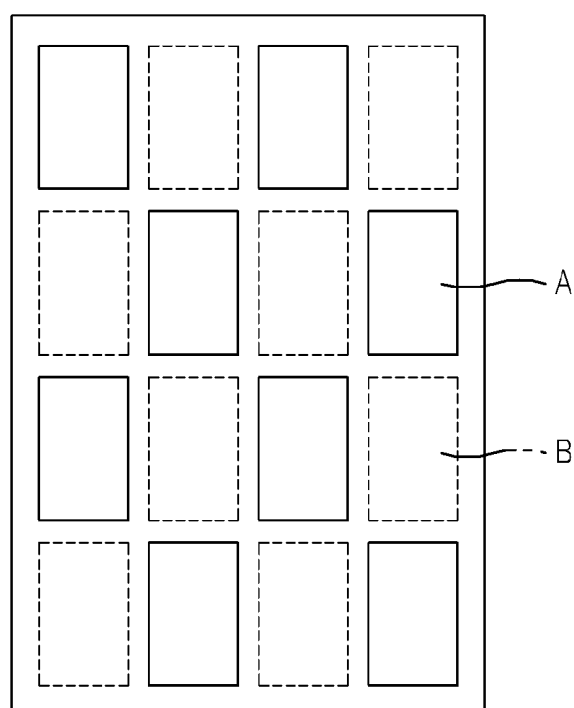


FIG. 3A

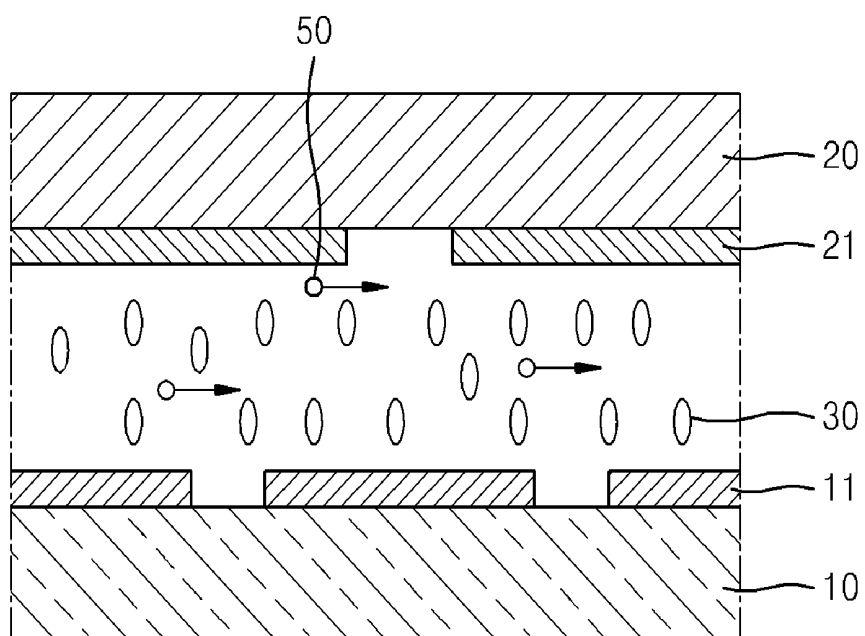


FIG. 3B

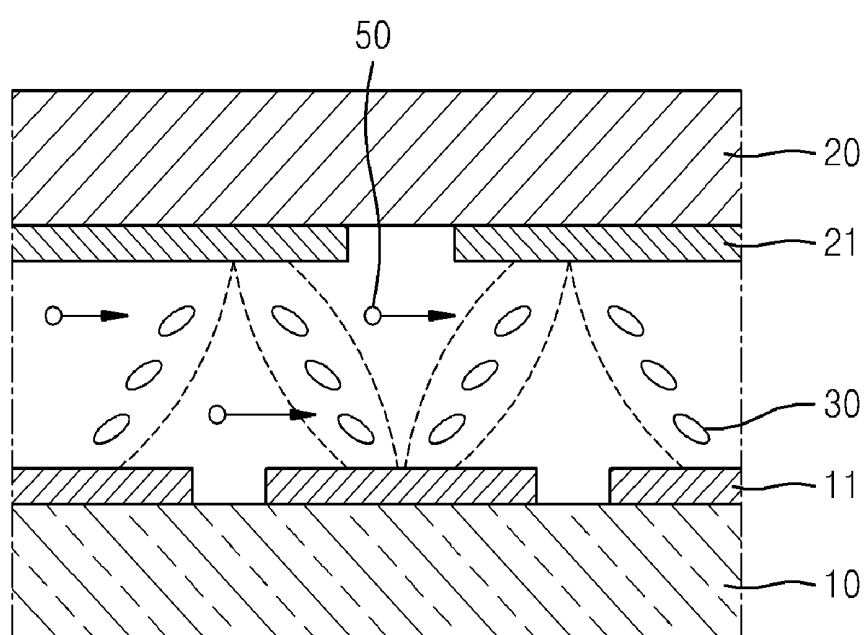


FIG. 4

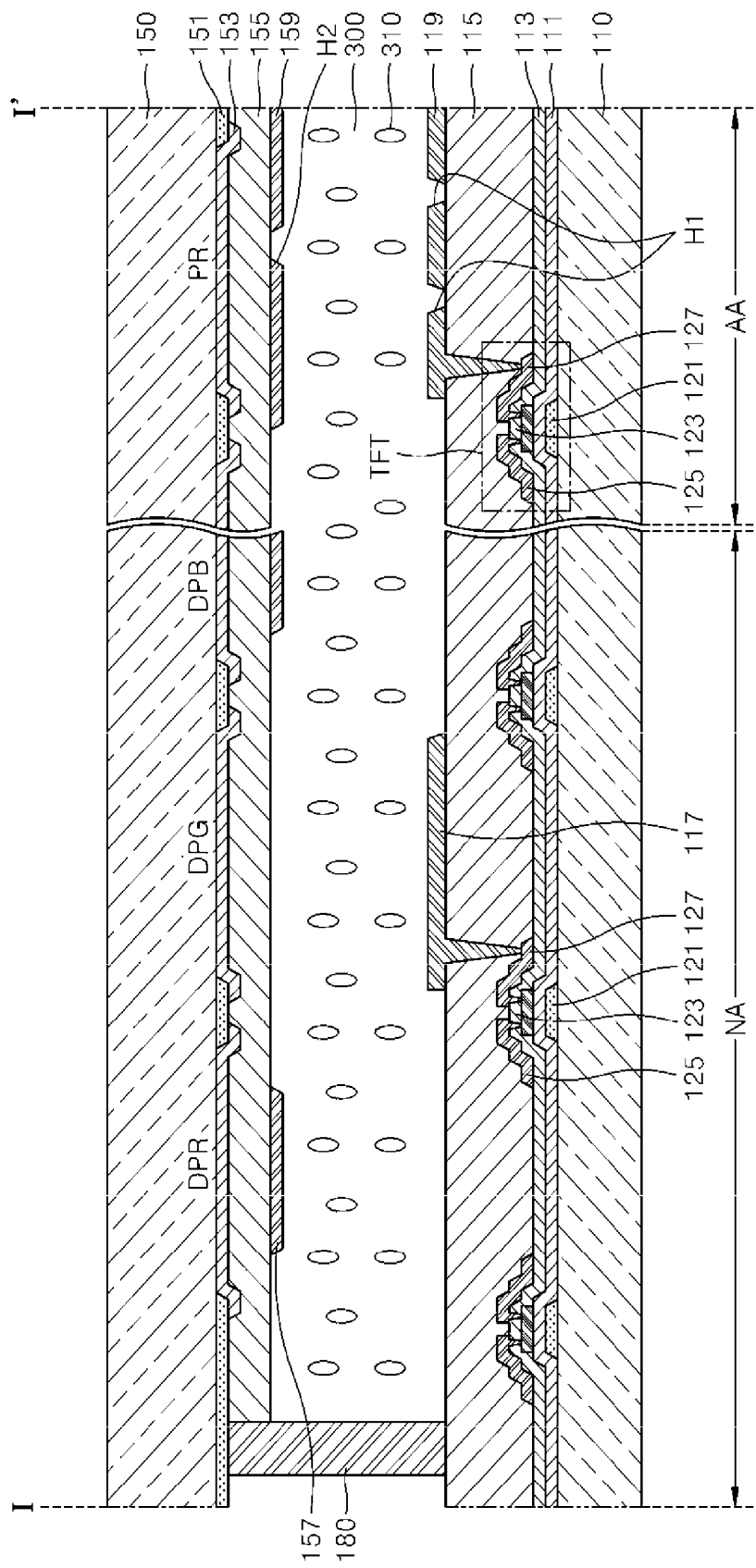


FIG. 5

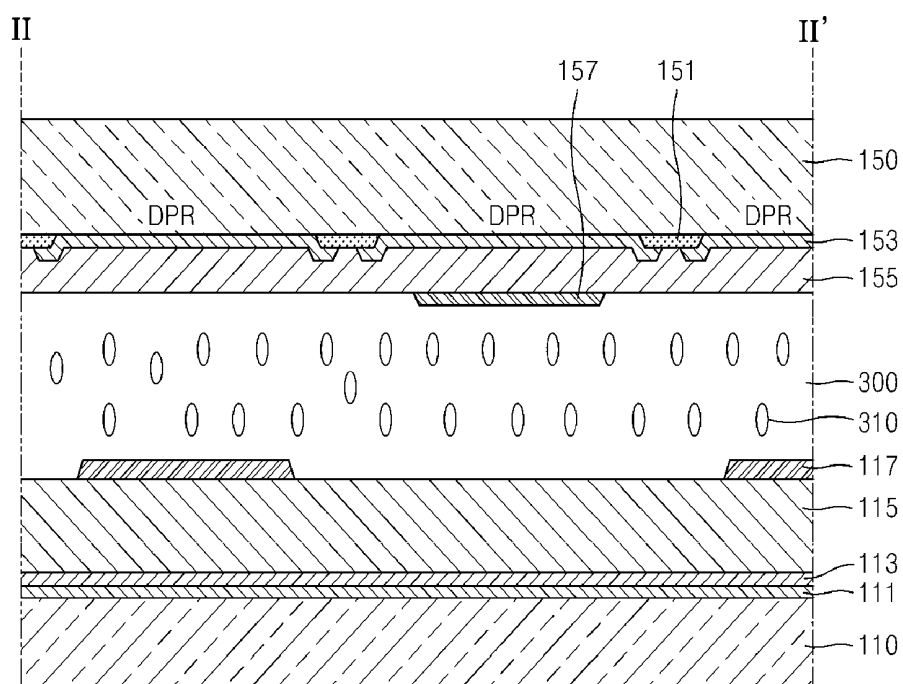


FIG. 6A

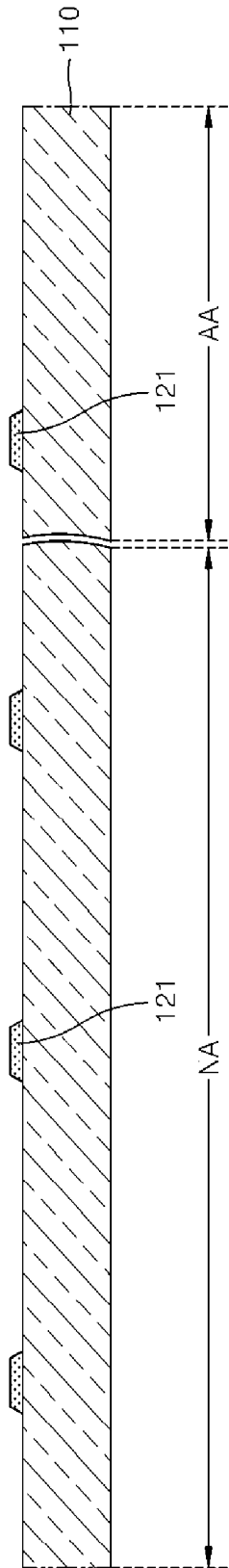


FIG. 6B

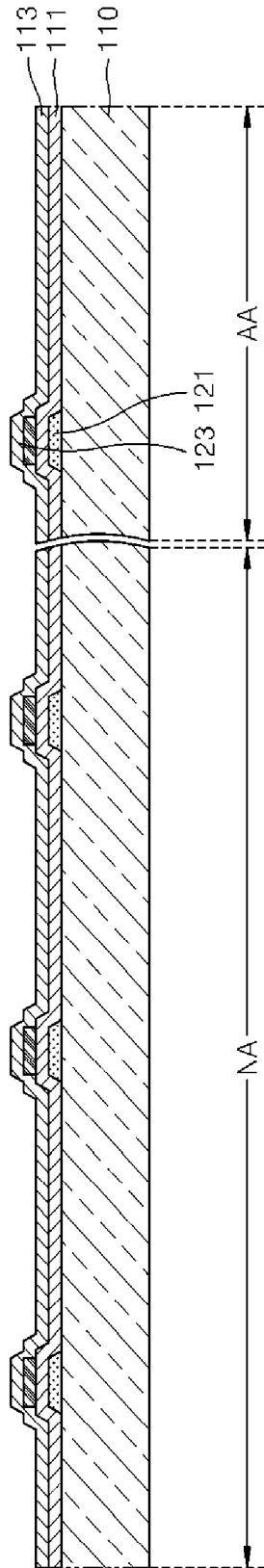


FIG. 6C

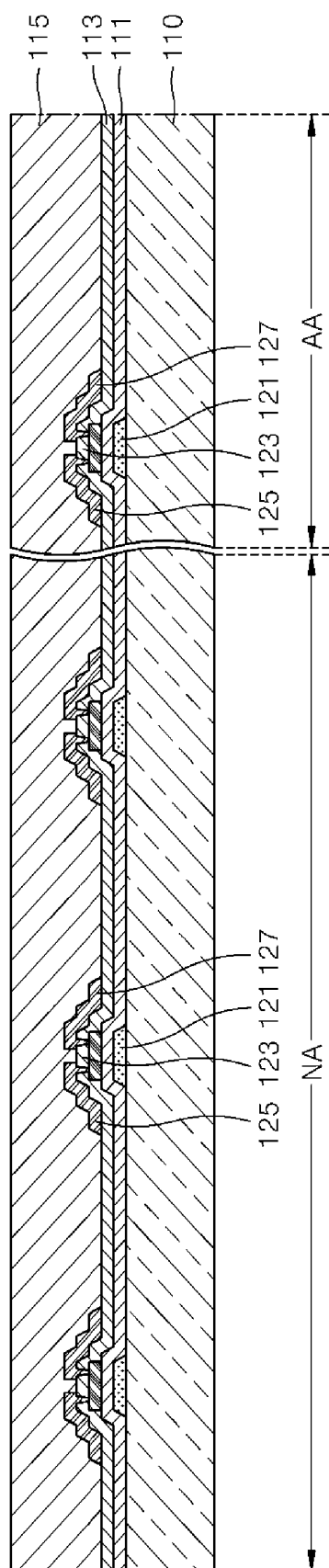


FIG. 6D

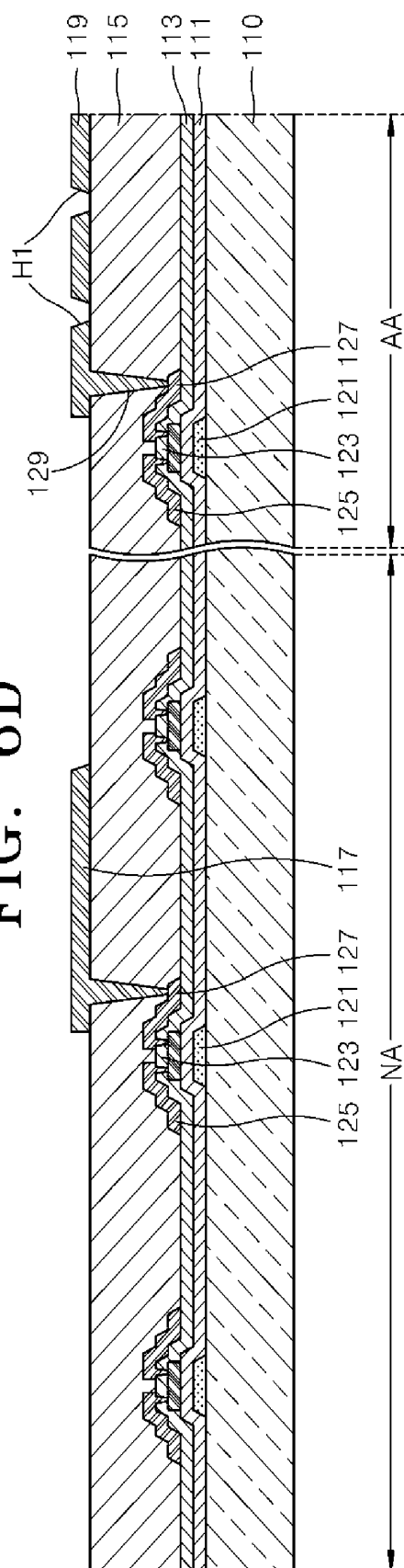


FIG. 7A

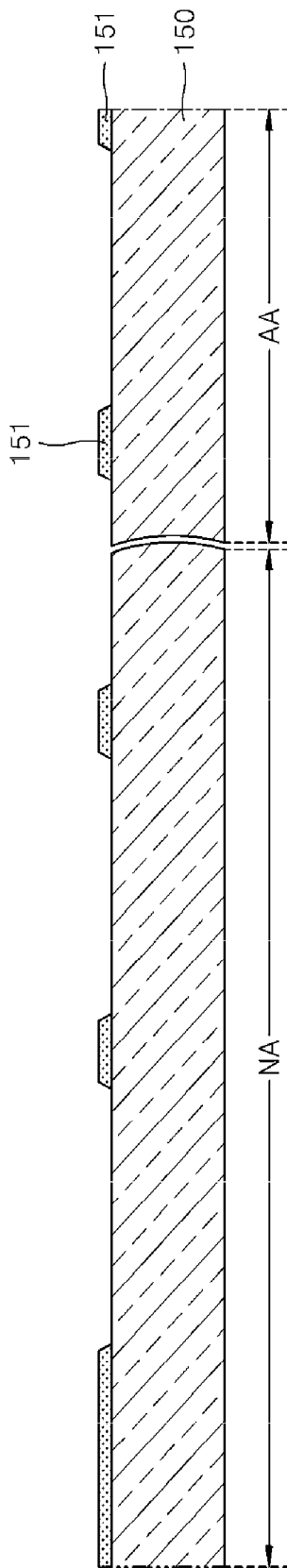


FIG. 7B

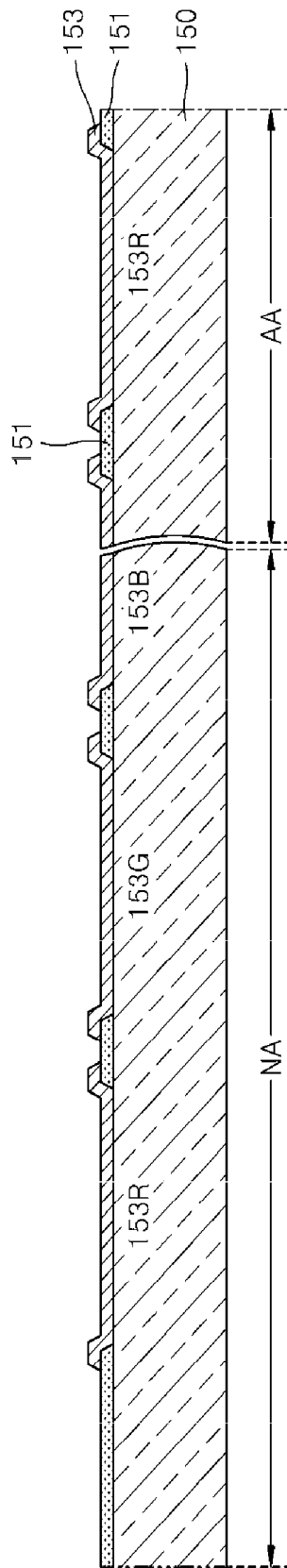


FIG. 7C

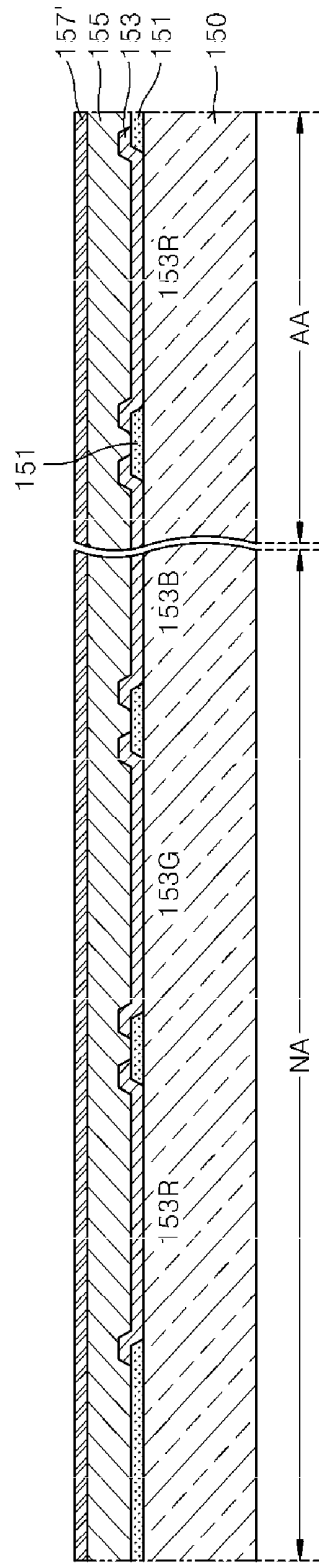


FIG. 7D

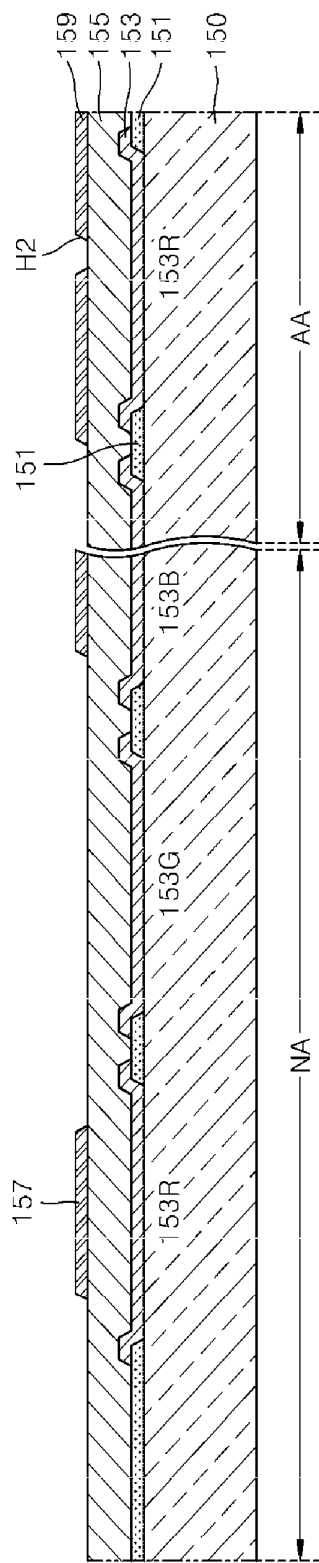
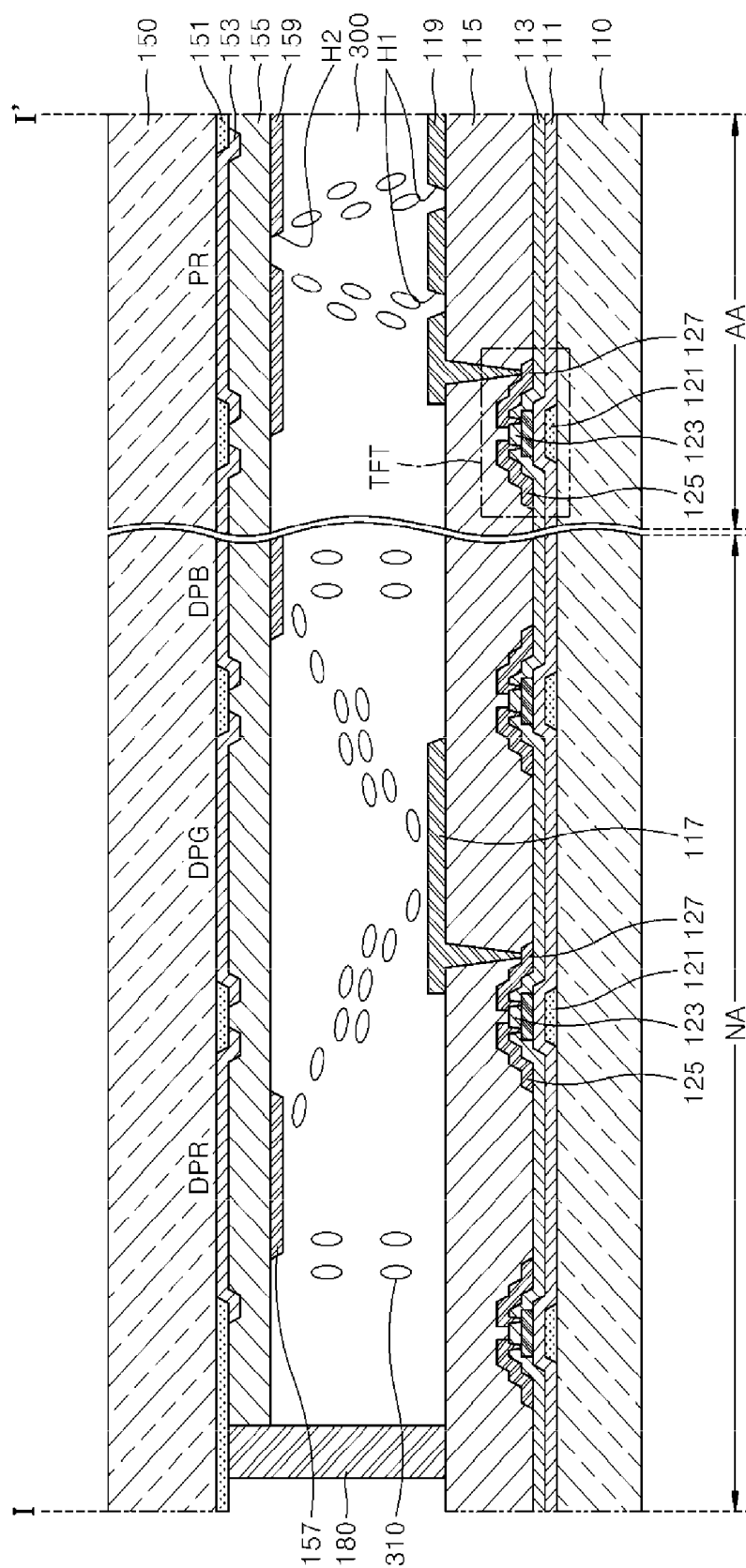


FIG. 8



LIQUID CRYSTAL DISPLAY DEVICE AND METHOD OF MANUFACTURING THE SAME

CROSS-REFERENCE TO RELATED APPLICATION

[0001] This application claims the benefit of Korean Patent Application No. 10-2010-0021019, filed Mar. 9, 2010, in the Korean Intellectual Property Office, the disclosure of which is incorporated herein by reference.

BACKGROUND

[0002] 1. Field

[0003] Aspects of the present invention generally relate to a Liquid Crystal Display (LCD) device, and more particularly, to an LCD device of which stains of an edge part is improved.

[0004] 2. Description of the Related Art

[0005] Liquid Crystal Display (LCD) devices are used as display devices of laptop computers and portable televisions due to the LCD devices having features of light weight, thinness, and low power consumption. The LCD devices display an image by inserting a liquid crystal substance between an upper substrate on which a common electrode and color filters are formed and a lower substrate on which thin film transistors (TFTs) and pixel electrodes are formed. The LCD devices change an arrangement of liquid crystal molecules with an electric field formed by applying different potentials to the pixel electrode and the common electrode, and adjusting a transmittance of light by using the arrangement change.

[0006] Such an LCD device can be classified into a horizontal electric field type LCD device and a vertical electric field type LCD device according to its driving scheme. The horizontal electric field type LCD device adjusts whether light is transmitted by controlling a motion of liquid crystal molecules in a horizontal direction. The vertical electric field type LCD device adjusts whether light is transmitted by controlling a motion of liquid crystal molecules in a vertical direction. From among the LCD devices, Vertical Alignment (VA) mode LCD devices, in which liquid crystal molecules are arranged so that a long axis of each of the liquid crystal molecules is perpendicular to upper and lower display panels, have been widely used due to a high contrast ratio and ease of realization of a wide reference view angle.

[0007] Various methods have been proposed to embody a wide view angle in such a VA mode LCD device, one of which is a Patterned VA (PVA) method arranging liquid crystal molecules to be perpendicular to upper and lower substrates and forming an opening pattern in a pixel electrode and a common electrode. In the PVA method, the liquid crystal molecules are divided and aligned by a fringe field, which is an oblique electric field appearing on the opening patterns, when a voltage is applied to the pixel electrode and the common electrode. In this case, the liquid crystal molecules are inclined and rearranged in a radial shape centering from the surroundings of the opening patterns to the outside, thereby transmitting light to display an image.

[0008] A mobile PVA (mPVA) mode, which is a kind of PVA method, divides each unit pixel into a plurality of domains and forms a pixel electrode consisting of sub-electrodes corresponding to respective domains. Since a single pixel can be divided into a plurality of domains and an inclined direction of liquid crystal molecules can be determined by adjusting a direction of an electric field, a reference viewing angle can be widened by dispersing the inclined

direction of liquid crystal molecules in various directions. When driving an mPVA mode LCD device, there is a problem wherein stains occur on an edge part of the LCD while ion impurities of a sealant forming a seal line of an outside area move to a display area.

SUMMARY

[0009] Aspects of the present invention provide a Liquid Crystal Display (LCD) device for improving edge part stains occurring due to ion impurities of a sealant and a method of manufacturing the same.

[0010] According to aspects of the present invention, there is provided a Liquid Crystal Display (LCD) device having dummy pixels in a non-display area comprising: a first substrate including first pixel electrodes of the plurality of dummy pixels; a second substrate facing the first substrate and including first common electrodes formed across and apart from the first pixel electrodes; and a liquid crystal layer, disposed between the first substrate and the second substrate, and having liquid crystal molecules rearranged by an electric field applied via the first pixel electrodes and the first common electrodes.

[0011] According to another aspect of the present invention, the first pixel electrodes may be formed on non-adjacent ones of the dummy pixels.

[0012] According to another aspect of the present invention, the LCD device may further comprise pixels in a display area, wherein the first substrate comprises switching elements and second pixel electrodes respectively electrically connected to the switching elements of every pixel, and the second substrate comprises second common electrodes facing the second pixel electrodes.

[0013] According to another aspect of the present invention, the first pixel electrodes and the second pixel electrodes may comprise the same electrode material or different electrode materials.

[0014] According to another aspect of the present invention, the first common electrode and the second common electrode may comprise the same electrode material or different electrode materials.

[0015] According to aspects of the present invention, there is provided a Liquid Crystal Display (LCD) device comprising: dummy pixels formed in a non-display area, each dummy pixel comprising one of a first pixel electrode and a first common electrode; pixels formed in a display area, each pixel comprising a second pixel electrode and a second common electrode, wherein the first common electrode is formed across and apart from a first pixel electrode, and wherein the second common electrode faces the second pixel electrode.

[0016] According to another aspect of the present invention, the first pixel electrode and the second pixel electrode may comprise the same electrode material or different electrode materials.

[0017] According to another aspect of the present invention, the first common electrode and the second common electrode may comprise the same electrode material or different electrode materials.

[0018] According to aspects of the present invention, there is provided a method of manufacturing a Liquid Crystal Display (LCD) device, the method comprising: forming a first substrate having first pixel electrodes of dummy pixels disposed in a non-display area and second pixel electrodes of pixels disposed in a display area; forming a second substrate having first common electrodes formed across and apart from

the first pixel electrodes and second common electrodes facing the second pixel electrodes; and disposing liquid crystal molecules between the first substrate and the second substrate.

[0019] Additional aspects and/or advantages of the invention will be set forth in part in the description which follows and, in part, will be obvious from the description, or may be learned by practice of the invention.

BRIEF DESCRIPTION OF THE DRAWINGS

[0020] These and/or other aspects and advantages of the invention will become apparent and more readily appreciated from the following description of the embodiments, taken in conjunction with the accompanying drawings of which:

[0021] FIG. 1 is a schematic top view of a Liquid Crystal Display (LCD) device according to an embodiment of the present invention;

[0022] FIG. 2A is a magnified view of an area D of FIG. 1;

[0023] FIG. 2B schematically illustrates an electrode pattern formed on dummy pixels;

[0024] FIGS. 3A and 3B are schematic diagrams illustrating a method of improving stains of an edge part, according to an embodiment of the present invention;

[0025] FIG. 4 is a magnified cross-sectional view through line I-I' of FIG. 2A;

[0026] FIG. 5 is a magnified cross-sectional view through line II-II' of FIG. 2A;

[0027] FIGS. 6A to 6D are cross-sectional views through line I-I' of FIG. 2A to illustrate a process of manufacturing a display substrate, according to an embodiment of the present invention;

[0028] FIGS. 7A to 7D are cross-sectional views through line II-II' of FIG. 2A to illustrate a process of manufacturing a facing substrate, according to an embodiment of the present invention; and

[0029] FIG. 8 illustrates liquid crystal arrangement when a voltage is applied to the display substrate and the facing substrate of the LCD device, according to an embodiment of the present invention.

DETAILED DESCRIPTION OF THE EMBODIMENTS

[0030] Reference will now be made in detail to the present embodiments of the present invention, examples of which are illustrated in the accompanying drawings, wherein like reference numerals refer to the like elements throughout. The embodiments are described below in order to explain the present invention by referring to the figures.

[0031] It is to be understood that where is stated herein that one element, film or layer is "formed on" or "disposed on" a second element, layer or film, the first element, layer or film may be formed or disposed directly on the second element, layer or film or there may be intervening element, layers or films between the first element, layer or film and the second element, layer or film. Further, as used herein, the term "formed on" is used with the same meaning as "located on" or "disposed on" and is not meant to be limiting regarding any particular fabrication process.

[0032] FIG. 1 is a schematic top view of a Liquid Crystal Display (LCD) device 100 according to an embodiment of the present invention. Referring to FIG. 1, the LCD device 100 has a structure in which a display substrate 110 and a facing substrate 150, each divided into a display area AA displaying

an image and a non-display area NA surrounding the display area AA, are closely combined, when liquid crystal being inserted between the display substrate 110 and the facing substrate 150. A liquid crystal panel includes the facing substrate 150, the display substrate 110, and a liquid crystal layer.

[0033] The display substrate 110 includes thin film transistors TFTs that are switching elements and a pixel electrode that is electrically connected to the TFTs. The facing substrate 150 includes a black matrix (not shown) shielding light incident from a backlight unit, a color filter layer including a color filter pattern in which red R, green G, and blue B are sequentially repeated, and a common electrode under the color filter layer, in this stated order.

[0034] In the display area AA, pixels P are defined on cross points of gate lines 221 to which a scan signal is applied and data lines 225 to which a data signal is applied, the plurality of data lines 225 perpendicularly crossing the plurality of gate lines 221. Each of the pixels P includes one of the TFTs, the second pixel electrode electrically connected to one of the TFTs, and the second common electrode facing the pixel electrode. In a non-display area NA close to the display area AA, dummy pixels DP (not shown) are defined. Each of the dummy pixels DP includes one the TFT, a first pixel electrode that is electrically connected to one of the TFTs, and the first common electrode formed across and apart from the pixel electrode.

[0035] In the non-display area NA of the liquid crystal panel, a seal line 180 is formed to fix the display substrate 110 and the facing substrate 150 to each other with a constant distance therebetween, after closely combining them. Along the seal line 180, a common voltage line (not shown) applying a voltage to the common electrodes is formed on the display substrate 110. The common voltage line and the common electrodes are electrified via the seal line 180 formed using a conductive sealant or short points formed on at least one of the four corner areas of the seal line 180.

[0036] FIG. 2A is a magnified view of an area D of FIG. 1, and FIG. 2B schematically illustrates an electrode pattern formed on dummy pixels DP. Referring to FIG. 2A, the liquid crystal panel includes red pixels PR, green pixels PG, and blue pixels PB. The liquid crystal panel also includes red dummy pixels DPR, green dummy pixels DPG, and blue dummy pixels DPB, which are respectively disposed outside the outermost red pixels PR, the outermost green pixels PG, and the outermost blue pixels PB.

[0037] The red pixels PR, the green pixels PG, and the blue pixels PB are each repeatedly formed in the display area AA of the liquid crystal panel in a column direction. Also, the red pixels PR, the green pixels PG, and the blue pixels PB are sequentially formed in a row direction. Likewise, the red dummy pixels DPR, the green dummy pixels DPG, and the blue dummy pixels DPB are repeatedly formed in the non-display area NA close to the display area AA of the liquid crystal panel in the column direction. Also, the red dummy pixels DPR, the green dummy pixels DPG, and the blue dummy pixels DPB are sequentially formed in the row direction. Although FIG. 2A illustrates a stripe-type arrangement of pixels and dummy pixels, aspects of the present invention are not limited to this arrangement.

[0038] The red dummy pixels DPR, the green dummy pixels DPG, and the blue dummy pixels DPB each include TFTs, first pixel electrodes formed on the display substrate 110, respective red, green, and blue color filters, and first common electrodes formed on the facing substrate 150. On the first

pixel electrodes and the first common electrodes, an opening pattern is formed. Each of the red dummy pixels DPR, the green dummy pixels DPG, and the blue dummy pixels DPB includes at most one of the first pixel electrodes and the first common electrodes, wherein the first pixel electrode is not formed one after another and the first common electrode is not formed one after another. For example, as illustrated in FIG. 2B, first pixel electrodes A and first common electrodes B are alternately formed in each row and column, i.e., formed across and apart from each other without overlapping each other.

[0039] Accordingly, if a voltage is applied to the first pixel electrode and the first common electrode, a fringe field may be formed between the first pixel electrode and the first common electrode. Each of the red pixels PR, the green pixels PG, and the blue pixels PB includes a TFT, a second pixel electrode formed on the display substrate 110, a red, a green, or a blue color filter, and a second common electrode formed on the facing substrate 150.

[0040] The second pixel electrode includes sub-electrodes on which an opening pattern is formed. According to aspects of the present invention, the opening pattern of the second pixel electrode is not limited, and various opening patterns may be used. The second common electrode is formed on the red, green, or blue color filter and has an opening pattern formed according to the opening pattern of the second pixel electrode. Each pixel P is divided into a plurality of domains by the opening patterns of the second pixel electrode and the second common electrode. Thus, the red pixels PR, the green pixels PG, and the blue pixels PB of the liquid crystal panel display an image by changing the arrangement of molecules of liquid crystal by a difference of potential applied to the second pixel electrode and the second common electrode.

[0041] FIGS. 3A and 3B are schematic diagrams illustrating a method of improving stains of an edge part, according to an embodiment of the present invention. FIG. 3A illustrates a case of liquid crystal molecules 30, arranged in a vertical direction, and displaying black when no voltage is applied between a display substrate 10 and a facing substrate 20. FIG. 3B illustrates a case of the liquid crystal molecules 30 inclined and rearranged in a radial shape due to a fringe field occurring in opening patterns of pixel electrodes 11 and common electrodes 21, and displaying white when a voltage is applied between the display substrate 10 and the facing substrate 20.

[0042] A moving speed of ion impurities 50 is faster in a case where the liquid crystal molecules 30 are arranged in the vertical direction compared to the case where the liquid crystal molecules 30 are inclined and arranged in the radial shape. This is because the ion impurities 50 receive more van der Waals forces when they pass through the inclined liquid crystal molecules 30.

[0043] Edge part stains of an LCD device are generated by the ion impurities 50 of a sealant that is a seal line existing in an outer area being dispersed into the display area AA. Therefore, aspects of the present invention arranges the liquid crystal molecules in the radial shape, as illustrated in FIG. 3(b), by having upper and lower electrodes, such as pixel electrode 11 and common electrode 21, across and apart from each other in dummy pixels formed on an outer black matrix area BM (not shown) of the non-display area NA and forming a fringe field between the upper and lower electrodes in a similar way to the display area AA. Accordingly, the ion impurities 50 are pre-

vented from moving to the display area AA, thereby reducing stains at an edge part of an LCD device.

[0044] FIG. 4 is a magnified cross-sectional view through line I-I' of FIG. 2A. Referring to FIG. 4, the LCD device 100 includes the display substrate 110, the facing substrate 150 facing the display substrate 110, and a liquid crystal layer 300 including liquid crystal molecules 310 between the display substrate 110 and the facing substrate 150. The liquid crystal molecules 310 are aligned in a perpendicular direction with respect to a surface of the display substrate 110 and the facing substrate 150. In the current embodiment, a red pixel PR, a red dummy pixel DPR, a green dummy pixel DPG, and a blue dummy pixel DPB are illustrated.

[0045] The display substrate 110 in the display area AA includes a TFT, which is a switching element, for every pixel P. The TFT is electrically connected to a second pixel electrode 119. In the present embodiment, the TFT of the red pixel PR is electrically connected to the second pixel electrode 119. The second pixel electrode 119 includes at least one opening H1 defining a plurality of domains in a unit pixel.

[0046] The display substrate 110 in the non-display area NA includes a TFT, which is a switching element, for every dummy pixel DP. One of the TFTs is electrically connected to a first pixel electrode 117 for every two dummy pixels DP in row and column directions. In the present embodiment, only a TFT of the green dummy pixel DPG disposed between the red dummy pixel DPR and the blue dummy pixel DPB is electrically connected to the first pixel electrode 117. However, aspects of the present invention are not limited thereto, and others of the TFTs may be electrically connected to the first pixel electrode 117. Although a TFT is disposed corresponding to every dummy pixel DP in the present embodiment, aspects of the present invention are not limited thereto, and a TFT may be formed only corresponding to a dummy pixel DP on which the first pixel electrode 117 is formed.

[0047] The first pixel electrode 117 is formed on the same layer as the second pixel electrode 119 and with a same electrode material or different electrode materials as the second pixel electrode 119. An opening pattern may be also formed in the first pixel electrode 117, in a manner similar as formed in the second pixel electrode 119. The second pixel electrode 119 is formed with a transparent conductive material, e.g., crystalline or non-crystalline Indium Tin Oxide (ITO) or Indium Zinc Oxide (IZO). Likewise, the first pixel electrode 117 may be formed with a transparent conductive material, e.g., crystalline or non-crystalline ITO or IZO. However, the first pixel electrode 117 may be formed with an opaque conductive metallic material, e.g., Mg, Al, Ni, Cr, Mo, W, MoW, Au or a combination of at least one of them, or other suitable materials.

[0048] The facing substrate 150 includes color filters 153; which includes a red (R) color filter corresponding to the red pixel PR, a red (R) color filter corresponding to the red dummy pixel DPR, a green (G) color filter corresponding to the green dummy pixel DPG, and a blue (B) color filter corresponding to the blue dummy pixel DPB. Black matrices 151 are disposed between the color filters 153. The color filters 153 and the black matrices 151 are covered by an overcoating layer 155. A first common electrode 157 and a second common electrode 159 are disposed on the overcoating layer 155. The black matrices 151 are formed between the color filters 153 and in the non-display area NA, partition

liquid crystal cells, shield light and block direct light irradiating onto TFTs so as to prevent a light leakage current of each TFT.

[0049] The second common electrode **159** is formed on the facing substrate **150** in the display area AA and has an opening H2 formed at a position corresponding to a portion in which the at least one opening H1 of the second pixel electrode **119** is not formed. In the current embodiment, the second common electrode **159** is formed on the red pixel PR to correspond to the second pixel electrode **119**.

[0050] The first common electrode **157** is formed on the facing substrate **150** in the non-display area NA at a location where the first pixel electrode **117** is not formed on a dummy pixel DP. Accordingly, the first pixel electrode **117** and the first common electrode **157** are disposed across the liquid crystal layer **300** and apart from each other so as to be not disposed directly across from each other across the crystal layer **300**. In the present embodiment, the first common electrode **157** is formed on the color filter **153** of the red dummy pixel DPR and the color filter **153** of the blue dummy pixel DPB.

[0051] The first common electrode **157** is formed on the same layer as the second common electrode **159** and with the same or different electrode material as the second common electrode **159**. An opening pattern H2 is additionally formed in the second common electrode **159**. The second common electrode **159** is formed with a transparent conductive material, e.g., crystalline or non-crystalline ITO or IZO. Likewise, the first common electrode **157** is formed with a transparent conductive material, e.g., crystalline or non-crystalline ITO or IZO. However, the first common electrode **157** may be formed with an opaque conductive metallic material, e.g., Mg, Al, Ni, Cr, Mo, W, MoW, Au or a combination of at least one of them, or other suitable materials.

[0052] FIG. 5 is a magnified cross-sectional view through line II-II' of FIG. 2A. Referring to FIG. 5, the present embodiment illustrates a portion of the red dummy pixels DPR and the dummy pixels DP (not shown) are disposed in the non-display area NA in the row direction.

[0053] A first pixel electrode **117** is formed on the display substrate **110** corresponding to every non-adjacent dummy pixel DP, and the first common electrode **157** is formed on the facing substrate **150** across and apart from the first pixel electrode **117**. In other words, the first pixel electrode **117** is not formed to be disposed on both of two directly adjacent dummy pixels DP. That is, the first pixel electrode **117** and the first common electrode **157** are disposed across and apart from each other without overlapping each other so that a fringe field is formed when an electric field is applied to the liquid crystal layer **300** via the first pixel electrode **117** and the first common electrode **157**.

[0054] FIGS. 6A to 6D are cross-sectional views through line I-I' of FIG. 2A and illustrate a process of manufacturing the display substrate **110**, according to an embodiment of the present invention. Referring to FIG. 6A, a gate electrode **121** is formed on the display substrate **110** in a predetermined pattern.

[0055] The display substrate **110** is formed of a transparent substrate and includes a transparent glass material of which a major component is SiO₂. However, aspects of the present invention are not limited thereto and the display substrate **110** may be formed of a transparent plastic material or another suitable material. An insulating layer (not shown) preventing dispersion of impurities, preventing infiltration of moisture or

the air, planarizing the surface and acting as a barrier layer and/or a buffer layer may be added to an upper surface of the display substrate **110**. The gate electrode **121** is formed by forming a gate metal layer (not shown) on the display substrate **110** and patterning the gate metal layer by a photolithography process.

[0056] Referring to FIG. 6B, a gate insulation film **111** is formed on the display substrate **110** having the gate electrode **121**. The gate insulation film **111** is formed by depositing an inorganic insulation film, e.g., Silicon Oxide or Silicon Nitride, by using a Plasma Enhanced Chemical Vapor Deposition (PECVD) method, an Atmospheric Pressure Chemical Vapor Deposition (APCVD) method, or a Low Pressure Chemical Vapor Deposition (LPCVD) method. However, aspects of the present invention are not limited thereto and the gate insulation film **111** may be formed of other suitable materials and may be formed using other suitable deposition methods.

[0057] An active layer **123** is formed on the gate insulation film **111** formed on the display substrate **110** so that the active layer **123** overlaps the gate electrode **121**. The active layer **123** is formed in a structure in which a semiconductor layer and an ohmic contact layer are layered. For example, the semiconductor layer includes amorphous silicon, and the ohmic contact layer includes amorphous silicon in which n-type or p-type impurities are doped in high density. An inter-layer insulation film **113** is formed on the display substrate **110** having the active layer **123**. However, aspects of the present invention are not limited thereto, and the inter-layer insulation film **113** may be omitted.

[0058] Referring to FIG. 6C, a source electrode **125** and a drain electrode **127**, respectively contacting both side portions of the active layer **123**, are formed on the display substrate **110** having the inter-layer insulation film **113**. To this end, holes are formed in the inter-layer insulation film **113** by etching a portion of the inter-layer insulation film **113** contacting side portions of the active layer **123**. The source and drain electrodes **125** and **127** are formed on the inter-layer insulation film **113** to fill the holes. However, aspects of the present invention are not limited thereto, and when the inter-layer insulation film **113** is omitted, the source and drain electrodes **125** and **127** may be formed to directly contact the both side portions of the active layer **123**.

[0059] A planarization film **115** is formed on the display substrate **110** having the source and drain electrodes **125** and **127**. The planarization film **115** is formed with an inorganic substance, e.g., Silicon Oxide or Silicon Nitride, and an organic substance having a good planarization characteristic and photosensitivity. However, aspects of the planarization layer are not limited thereto, and the planarization film **115** may be formed of other suitable materials. The planarization film **115** may be formed in a structure in which an inorganic film and an organic film are layered.

[0060] Referring to FIG. 6D, a hole **129** exposing one of the source and drain electrodes **125** and **127** is formed in the planarization film **115** by patterning the planarization film **115**. The hole **129** exposes one of the source and drain electrodes **125** and **127** of a TFT disposed corresponding to each pixel in the display area AA. The hole **129** also exposes one of the source and drain electrodes **125** and **127** of a TFT disposed corresponding to each of the dummy pixels DP not having the first common electrode **157**.

[0061] A transparent electrode layer (not shown) is formed on the display substrate **110** having the hole **129**, and the first

pixel electrode **117** and the second pixel electrode **119** are formed by patterning the transparent electrode layer. Examples of a material forming the transparent electrode layer are ITO and IZO. However, aspects of the present invention are not limited thereto, and the transparent electrode may be formed of other suitable materials.

[0062] The first pixel electrode **117** is formed with a transparent electrode material different from that of the second pixel electrode **119** or with an opaque electrode material. In this case, the transparent electrode layer (not shown) is formed on the display substrate **110** in the display area AA, and a transparent electrode layer made of another electrode material or an electrode layer made of an opaque electrode material is formed on the display substrate **110** in the non-display area NA. The opaque electrode material is a conductive metallic material, such as Mg, Al, Ni, Cr, Mo, W, MoW, Au, or other suitable materials or a combination of at least one of them.

[0063] At least one opening H1 is formed in the second pixel electrode **119**, and the second pixel electrode **119** is divided into a plurality of domains by the at least one opening H1. Although not shown, at least one opening may also be formed in the first pixel electrode **117**. In the present embodiment, a bottom gate type TFT is illustrated as an example of the TFT. However, aspects of the present invention are not limited thereto and another type of TFT, e.g., a top gate type TFT, may be used instead. Although not shown, an alignment film aligning liquid crystal molecules may be additionally formed on the display substrate **110** on which the first pixel electrode **117** and the second pixel electrode **119** are formed.

[0064] FIGS. 7A to 7D are cross-sectional views through II-II' of FIG. 2A and illustrate a process of manufacturing the facing substrate **150**, according to an embodiment of the present invention. Referring to FIG. 7A, the black matrix **151** is formed on the facing substrate **150** in a predetermined pattern.

[0065] The facing substrate **150** is formed with a transparent substrate and includes a transparent glass material of which a major component is SiO₂, or a transparent plastic material. The black matrix **151** is formed by injecting organic ink or patterning a metal layer by a photolithography process. The black matrix **151** is formed with Cr, CrOx, or an organic black matrix. However, aspects of the present invention are not limited thereto, and the facing substrate **150** and the black matrix **151** may be formed of other suitable materials.

[0066] Referring to FIG. 7B, the color filters **153** are formed on the facing substrate **150** having the black matrix **151** is formed. The color filters **153** include red, green, and blue color filters **153R**, **153G**, and **153B** selectively transmitting only light having a predetermined wavelength. The red, green, and blue color filters **153R**, **153G**, and **153B** are formed in a stripe or mosaic type according to an arrangement method. The color filters **153** are formed by patterning a color photoresist layer by a photolithography process or injecting color ink. However, aspects of the present invention are not limited thereto and the color filters **153** may be formed to be other types of arrangements and by other processes.

[0067] Referring to FIG. 7C, the overcoating layer **155** is formed on the facing substrate **150** having the black matrix **151** and the red, green, and blue color filters **153R**, **153G**, and **153B**. The overcoating layer **155** planarizes the facing substrate **150** and is formed of a transparent material. An example of the material forming the overcoating layer **155** is an acrylic resin. A transparent electrode layer **157'** is formed on the

facing substrate **150** having the overcoating layer **155**. Examples of a material used to form the transparent electrode layer **157'** are ITO and IZO. The transparent electrode layer **157'** is patterned into the first common electrode **157** and the second common electrode **159**.

[0068] The first common electrode **157** is formed with a transparent electrode material that is different from that of the second common electrode **159** or with an opaque electrode material. In this case, the transparent electrode layer **157'** is formed on the facing substrate **150** in the display area AA, and a transparent electrode layer made of another electrode material or an electrode layer made of an opaque electrode material is formed on the facing substrate **150** in the non-display area NA. The opaque electrode material is a conductive metallic material, e.g., Mg, Al, Ni, Cr, Mo, W, MoW, Au, or other suitable materials or a combination of at least two of them.

[0069] Referring to FIG. 7D, the first common electrode **157** is disposed across and apart from the first pixel electrode **117** and the second common electrode **159** faces the second pixel electrode **119**. The first common electrode **157** and the second common electrode **159** are formed by patterning the transparent electrode layer **157'**. If electrode layers forming the first common electrode **157** and the second common electrode **159** are made of different electrode materials, then the electrode layers are respectively patterned into the first common electrode **157** and the second common electrode **159**.

[0070] At least one opening H2 is formed in the second common electrode **159** so that the at least one opening H2 is across from and not disposed directly on top of the at least one opening H1 of the second pixel electrode **119**. The second common electrode **159** is divided into a plurality of domains by the at least one opening H2. In another example, at least one opening (not shown) may be formed in the first common electrode **157**. Although not shown, an alignment film aligning liquid crystal molecules may be additionally formed on the facing substrate **150** on which the first common electrode **157** and the second common electrode **159** are formed.

[0071] FIG. 8 illustrates liquid crystal arrangement when a voltage is applied to the display substrate **110** and the facing substrate **150** of the LCD device **100**, according to an embodiment of the present invention. Referring to FIG. 8, a basic structure of the LCD device **100**, manufactured according to an embodiment of the present invention, is made by arranging and combining the display substrate **110** manufactured in the process of FIGS. 6A to 6D and the facing substrate **150** manufactured in the process of FIGS. 7A to 7D. Additionally, the liquid crystal layer **300** is disposed between the display substrate **110** and the facing substrate **150** and is perpendicularly aligned.

[0072] The LCD device **100** is made by disposing components, such as a polarizing plate (not shown) and a backlight (not shown), on the basic structure of the LCD device **100**. In this case, the polarizing plate is disposed onto both sides of the basic structure. The display substrate **110** and the facing substrate **150** are arranged so that the second pixel electrode **119** overlaps the color filter **153** in the display area AA. Accordingly, each pixel P is divided into a plurality of domains by the at least one opening H1 of the second pixel electrode **119** and the at least one opening H2 of the second common electrode **159**. Thus, when an electric field is applied to the liquid crystal layer **300**, a fringe field is formed between the second pixel electrode **119** and the second common elec-

trode 159. As a result, a wide view angle may be secured by the re-arranging of liquid crystal molecules.

[0073] In addition, the display substrate 110 and the facing substrate 150 are arranged so that the first pixel electrode 117 and the first common electrode 157 are disposed across and apart from each other in the non-display area NA. In other words, the first pixel electrode 117 and the first common electrode 157 are formed so as to be across the liquid crystal layer 300 from each other and are formed so as to not be directly facing each other. Accordingly, when an electric field is applied to the liquid crystal layer 300, the first pixel electrode 117 and the first common electrode 157 of dummy pixels DP form a fringe field. As a result, the liquid crystal molecules 310 are rearranged in a radial shape, thereby preventing ion impurities 50 generated in an outer edge part from moving into the display area AA.

[0074] The LCD device 100 according to aspects of the present invention is used in devices such as a Portable Multimedia Player (PMP), a Personal Digital Assistant (PDA), a portable Digital Versatile Disk (DVD) player, a cellular phone, a laptop computer, and a digital television. However, aspects of the present invention are not limited thereto and the LCD device 100 may be used in other devices using a display screen.

[0075] According to aspects of the present invention, liquid crystal molecules 310 are inclined and rearranged in a radial shape by a fringe field from upper and lower electrodes, such as the first pixel electrode 117 and the first common electrode 157. The upper and lower electrodes are patterned to be across and apart from each other on dummy pixels DP disposed on a black matrix 151 formed in a non-display area NA of an LCD device 100. The fringe field is formed by applying an electric field to a liquid crystal layer via the patterned upper and lower electrodes. Thus, ion impurities 50 in the non-display area NA are largely prevented from dispersing to a display area AA, thereby improving edge part stains of the LCD device 100.

[0076] Although a few embodiments of the present invention have been shown and described, it would be appreciated by those skilled in the art that changes may be made in this embodiment without departing from the principles and spirit of the invention, the scope of which is defined in the claims and their equivalents.

What is claimed is:

1. A Liquid Crystal Display (LCD) device having dummy pixels in a non-display area comprising:

- a first substrate including first pixel electrodes of the dummy pixels;
- a second substrate facing the first substrate and including first common electrodes formed across and apart from the first pixel electrodes; and
- a liquid crystal layer disposed between the first substrate and the second substrate, and having liquid crystal molecules rearranged by an electric field applied via the first pixel electrodes and the first common electrodes.

2. The LCD device of claim 1, wherein the first pixel electrodes are formed on non-adjacent ones of the dummy pixels.

3. The LCD device of claim 1, wherein the first pixel electrodes comprises a transparent electrode material.

4. The LCD device of claim 1, wherein the first pixel electrodes comprises an opaque metallic material.

5. The LCD device of claim 1, wherein the first common electrodes comprises a transparent electrode material.

6. The LCD device of claim 1, wherein the first common electrodes comprises an opaque metallic material.

7. The LCD device of claim 1, wherein the first substrate further comprises switching elements that are electrically connected to the first pixel electrodes.

8. The LCD device of claim 1, further comprising pixels in a display area,

wherein the first substrate comprises:

- switching elements; and
- second pixel electrodes respectively electrically connected to the switching elements of every pixel, and wherein the second substrate comprises second common electrodes facing the second pixel electrodes.

9. The LCD device of claim 8, wherein the second pixel electrodes and the second common electrodes comprise at least one opening and are divided into a plurality of domains by the at least one opening.

10. A Liquid Crystal Display (LCD) device comprising:

dummy pixels formed in a non-display area, each dummy pixel comprising one of a first pixel electrode and a first common electrode; and

pixels formed in a display area, each pixel comprising:

- a second pixel electrode; and
- a second common electrode,

wherein the first common electrode is formed across and apart from a first pixel electrode, and

wherein the second common electrode faces the second pixel electrode.

11. The LCD device of claim 10, wherein the first pixel electrode is formed on non-adjacent ones of the plurality of dummy pixels.

12. The LCD device of claim 10, wherein the first pixel electrode and the second pixel electrode are formed of the same electrode material.

13. The LCD device of claim 10, wherein the first pixel electrode and the second pixel electrode are formed of different electrode materials.

14. The LCD device of claim 10, wherein the first common electrode and the second common electrode comprise the same electrode material.

15. The LCD device of claim 10, wherein the first common electrode and the second common electrode comprise different electrode materials.

16. A method of manufacturing a Liquid Crystal Display (LCD) device, the method comprising:

forming a first substrate having first pixel electrodes of dummy pixels disposed in a non-display area and second pixel electrodes of pixels disposed in a display area;

forming a second substrate having first common electrodes formed across and apart from the first pixel electrodes and second common electrodes facing the second pixel electrodes; and

disposing liquid crystal molecules between the first substrate and the second substrate.

17. The method of claim 16, wherein the manufacturing of the first substrate comprises:

forming the first pixel electrodes on non-adjacent ones of the plurality of dummy pixels; and

forming the second pixel electrodes corresponding to each of the pixels.

18. The method of claim 16, wherein the first pixel electrodes and the second pixel electrodes comprise the same electrode material.

19. The method of claim **16**, wherein the first pixel electrodes and the second pixel electrodes comprise different electrode materials.

20. The method of claim **16**, wherein the first common electrodes and the second common electrodes are formed of the same electrode material.

21. The method of claim **16**, wherein the first common electrodes and the second common electrodes comprise different electrode materials.

22. The LCD device of claim **2**, wherein the non-adjacent ones of the dummy-pixels are every other ones of a series of dummy pixels.

23. The LCD device of claim **11**, wherein the non-adjacent ones of the dummy-pixels are every other ones of a series of dummy pixels.

24. The method of claim **17**, wherein the non-adjacent ones of the dummy-pixels are every other ones of a series of dummy pixels.

25. The LCD device of claim **1**, wherein the first common electrodes are disposed so as to be not directly facing the first pixel electrodes.

26. The LCD device of claim **10**, wherein the first common electrode is disposed so as to be not directly facing the first pixel electrode.

27. The method of claim **16**, wherein the first common electrodes are formed so as to be not directly facing the first pixel electrodes.

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专利名称(译)	液晶显示装置及其制造方法		
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[标]申请(专利权)人(译)	三星显示有限公司		
申请(专利权)人(译)	三星移动显示器有限公司.		
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发明人	LEE, DAE-WON PARK, KYUNG-MIN		
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摘要(译)

提供了一种液晶显示 (LCD) 装置及其制造方法。通过在设置在形成于 LCD 装置的非显示区域中的黑矩阵上的虚设像素上将上电极和下电极彼此交叉和分开地图案化并且将电场施加到电极上, 液晶分子以径向形状倾斜和重新排列。液晶层通过上下电极。因此, 可以防止非显示区域中的离子杂质分散到显示区域, 从而改善 LCD 装置的边缘部分污点。 LCD 装置包括第一基板, 第一基板包括虚设像素的第一像素电极; 第二基板, 其面对第一基板并包括形成在第一像素电极上并与第一像素电极分开的第一公共电极; 液晶层设置在第一基板和第二基板之间, 并且具有通过经由第一像素电极和第一公共电极施加的电场而重新排列的液晶分子。

